

L Number	Hits	Search Text	DB	Time stamp
5	1351	(oda pmda) and (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 14:50
6	627	(oda.u/c. pmda.u/c.) and (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 14:50
7	482402	(electric electrical magnetic magnet) near field	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 14:50
8	1351	((oda pmda) and (resist photoresist)) ((oda.u/c. pmda.u/c.) and (resist photoresist))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 14:50
9	238	((oda pmda) and (resist photoresist)) ((oda.u/c. pmda.u/c.) and (resist photoresist)) and ((electric electrical magnetic magnet) near field)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 14:51
10	40182	electromagnetic near field	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 14:51
11	503201	((electric electrical magnetic magnet) near field) (electromagnetic near field)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 14:51
12	243	((oda pmda) and (resist photoresist)) ((oda.u/c. pmda.u/c.) and (resist photoresist)) and ((electric electrical magnetic magnet) near field) (electromagnetic near field))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 14:52
13	116	((oda pmda) and (resist photoresist)) ((oda.u/c. pmda.u/c.) and (resist photoresist)) and ((electric electrical magnetic magnet) near field) (electromagnetic near field)) and plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 15:01
14	33719	\$5polarized adj light	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 15:01
16	4	((oda pmda) and (resist photoresist)) ((oda.u/c. pmda.u/c.) and (resist photoresist)) and ((electric electrical magnetic magnet) near field) (electromagnetic near field)) and plasma and (\$5polarized adj light)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 15:28
17	2	("6280911").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 15:32
18	2	("6277539").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 15:58
19	4489	((electric electrical magnetic magnet) near field) (electromagnetic near field)) same (xray x-ray)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 15:59
20	2888	((electric electrical magnetic magnet) near field) (electromagnetic near field)) same (xray x-ray)	USPAT	2004/04/18 16:00
-	2	("20030022099").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/30 13:26

-	30985	oda pmida	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 10:33
-	1222	(oda pmida) and (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 14:49
-	9552	oda pmida	USPAT	2003/07/29 10:32
-	957	(oda pmida) and (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 10:35
-	22709	oda.u/c. pmida.u/c.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 10:33
-	584	(oda.u/c. pmida.u/c.) and (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 14:50
-	33376	polarized adj light	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 10:47
-	444522	(electric electrical magnetic magnet) near field	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 14:50
-	208081	((polarized adj light) ((s p)-polarized)) and ((electric electrical magnetic magnet) near field)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/30 14:00
-	51	((polarized adj light) ((s p)-polarized)) and ((electric electrical magnetic magnet) near field) and ((oda.u/c. pmida.u/c.) and (resist photoresist))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 18:33
-	291	LIN-SHUN LIN-SHUN-LI HSU-W HSU-WEI HSU-WEI-H HSU-WEI-HSUAN HSU-WEI-HUA	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 11:06
-	1	((LIN-SHUN LIN-SHUN-LI HSU-W HSU-WEI HSU-WEI-H HSU-WEI-HSUAN HSU-WEI-HUA) and (((polarized adj light) ((s p)-polarized)) and ((electric electrical magnetic magnet) near field)) and ((oda.u/c. pmida.u/c.) and (resist photoresist)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 11:05
-	1	((LIN-SHUN LIN-SHUN-LI HSU-W HSU-WEI HSU-WEI-H HSU-WEI-HSUAN HSU-WEI-HUA) and (oda pmida))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 11:06
-	5	((LIN-SHUN LIN-SHUN-LI HSU-W HSU-WEI HSU-WEI-H HSU-WEI-HSUAN HSU-WEI-HUA) and (((polarized adj light) ((s p)-polarized)) and ((electric electrical magnetic magnet) near field)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 12:01
-	14	((LIN-SHUN LIN-SHUN-LI HSU-W HSU-WEI HSU-WEI-H HSU-WEI-HSUAN HSU-WEI-HUA) and (resist photoresist))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 11:06
-	15	((LIN-SHUN LIN-SHUN-LI HSU-W HSU-WEI HSU-WEI-H HSU-WEI-HSUAN HSU-WEI-HUA) and (((polarized adj light) ((s p)-polarized)) and ((electric electrical magnetic magnet) near field))) ((LIN-SHUN LIN-SHUN-LI HSU-W HSU-WEI HSU-WEI-H HSU-WEI-HSUAN HSU-WEI-HUA) and (resist photoresist))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 18:33

-	50	(( (polarized adj light ) ((s p)-polarized)) and ((electric electrical magnetic magnet) near field)) and ((oda.u/c. pmida.u/c.) and (resist photoresist))) not (((LIN-SHUN LIN-SHUN-LI HSU-W HSU-WEI HSU-WEI-H HSU-WEI-HSUAN HSU-WEI-HUA) and ((polarized adj light ) ((s p)-polarized)) and ((electric electrical magnetic magnet) near field))) ((LIN-SHUN LIN-SHUN-LI HSU-W HSU-WEI HSU-WEI-H HSU-WEI-HSUAN HSU-WEI-HUA) and (resist photoresist))) (("6542055") or ("6535080")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 12:00
-	4		USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 12:00
-	4170	s-polarized p-polarized	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 12:01
-	34201	(s-polarized p-polarized) (polarized adj light )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 12:01
-	8896	((s-polarized p-polarized) (polarized adj light )) and ((electric electrical magnetic magnet) near field)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 12:01
-	3	((LIN-SHUN LIN-SHUN-LI HSU-W HSU-WEI HSU-WEI-H HSU-WEI-HSUAN HSU-WEI-HUA) and ((s-polarized p-polarized) (polarized adj light )) and ((electric electrical magnetic magnet) near field))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 12:02
-	1032	((s-polarized p-polarized) (polarized adj light )) and ((electric electrical magnetic magnet) near field)) and (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 12:04
-	5	((((s-polarized p-polarized) (polarized adj light )) and ((electric electrical magnetic magnet) near field)) and (resist photoresist)) and (oda.u/c. pmida.u/c.)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 12:14
-	5511	(PMDA.u/c.) pyromellitic adj dianhydride	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 12:16
-	27956	(ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 18:54
-	2103	((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 12:23
-	53	((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 12:18
-	5	((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))) AND (RESIST PHOTORESIST)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 12:24

	1	((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))) AND (RESIST PHOTORESIST)) NOT (((((s-polarized p-polarized) (polarized adj light )) and ((electric electrical magnetic magnet) near field)) and (resist photoresist)) and (oda.u/c. pmda.u/c.))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 12:19
	48	((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))) NOT (((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))) AND (RESIST PHOTORESIST))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/29 12:19
	49	(((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))) AND (RESIST PHOTORESIST)) NOT (((((s-polarized p-polarized) (polarized adj light )) and ((electric electrical magnetic magnet) near field)) and (resist photoresist)) and (oda.u/c. pmda.u/c.))) (((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))) NOT (((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))) AND (RESIST PHOTORESIST))))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 18:55
	2	("6277539").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/30 13:43
	216	pmda-oda	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/30 13:43
	23	pmda-oda same (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 12:24
	0	(pmda-oda same (resist photoresist)) and (polarized near light)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/30 14:00
	208081	( (polarized adj light ) ((s p)-polarized)) and ((electric electrical magnetic magnet) near field)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/07/30 14:01

-	37926	electromagnetic adj field	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 11:57
-	2606	photosensitive adj polymer	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 11:57
-	37071	polarized adj light	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 11:57
-	338	anti-etching antietching (anti adj etching)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 11:58
-	868631	absorbing absorb absorbed	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 11:58
-	38163	plasma adj etch\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 11:59
-	0	(electromagnetic adj field) and (photosensitive adj polymer ) and (polarized adj light) and (absorbing absorb absorbed ) and (anti-etching antietching (anti adj etching)) and (plasma adj etch\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 11:59
-	381041	plasma	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 11:59
-	1	(photosensitive adj polymer ) and (polarized adj light) and (anti-etching antietching (anti adj etching)) and (absorbing absorb absorbed ) and (plasma adj etch\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 12:18
-	455212	(electric magnetic) adj field	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 12:18
-	476175	electromagnetic adj field) ((electric magnetic) adj field	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 12:18
-	1	((electromagnetic adj field) ((electric magnetic) adj field)) and (polarized adj light) and (anti-etching antietching (anti adj etching)) and (absorbing absorb absorbed )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 18:33
-	0	((electromagnetic adj field) ((electric magnetic) adj field)) and (polarized adj light) and (anti-etching antietching (anti adj etching)) and (absorbing absorb absorbed ) not ((photosensitive adj polymer ) and (polarized adj light) and (anti-etching antietching (anti adj etching)) and (absorbing absorb absorbed ) and (plasma adj etch\$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 12:19
-	2213	((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 12:24
-	2213	((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 12:24

-	2213	((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 12:24
-	52	(((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))) AND (RESIST PHOTORESIST)) NOT (((((s-polarized p-polarized) (polarized adj light )) and ((electric electrical magnetic magnet) near field)) and (resist photoresist)) and (oda.u/c. pmda.u/c.))) (((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))) NOT (((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))) AND (RESIST PHOTORESIST)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 12:24
-	5	((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))) AND (RESIST PHOTORESIST))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 18:56
-	24	pmda-oda same (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/02 13:20
-	56	(( (polarized adj light ) ((s p)-polarized)) and ((electric electrical magnetic magnet) near field)) and ((oda.u/c. pmda.u/c.) and (resist photoresist))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 20:58
-	820	(oxygen adj plasma) same (electromagnetic magnetic electric )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 21:07
-	354	((oxygen adj plasma) same (electromagnetic magnetic electric )) and (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 21:07
-	6	((oxygen adj plasma) same (electromagnetic magnetic electric )) and (resist photoresist)) and (polarized adj light)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 20:38
-	131	(electric adj field) same (oxygen adj plasma)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 18:43
-	98	(magnetic adj field) same (oxygen adj plasma)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 18:44
-	1	((electromagnetic adj field) ((electric magnetic) adj field)) and (polarized adj light) and (anti-etching antietching (anti adj etching)) and (absorbing absorb absorbed )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 18:54
-	0	20030022099.URPN.	USPAT	2004/04/15 18:54



-	53	(((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))) AND (RESIST PHOTORESIST)) NOT (((((s-polarized p-polarized) (polarized adj light )) and ((electric electrical magnetic magnet) near field)) and (resist photoresist)) and (oda.u/c. pmda.u/c.))) (((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))) NOT (((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))) AND (RESIST PHOTORESIST))) pyralin	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 20:42
-	261		USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 20:58
-	258324	(polarized adj light) ((s p)-polarized) and ((electric electrical magnetic magnet) near field)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 20:59
-	38	pyralin and ( (polarized adj light) ((s p)-polarized) and ((electric electrical magnetic magnet) near field) )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 20:59
-	4596198	(electromagnetic magnetic electric )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 21:08
-	8119	((electromagnetic magnetic electric )) and ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 21:07
-	575	((electromagnetic magnetic electric )) and ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) and (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 21:07
-	478022	(electromagnetic magnetic electric ) adj field	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 21:08
-	142	((electromagnetic magnetic electric ) adj field ) and ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE ) and (resist photoresist)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 21:08

-	137	((electromagnetic magnetic electric ) adj field ) and ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE ) and (resist photoresist)) not (((((oxygen adj plasma) same (electromagnetic magnetic electric )) and (resist photoresist)) and (polarized adj light)) (((electromagnetic adj field) ((electric magnetic) adj field)) and (polarized adj light) and (anti-etching antietching (anti adj etching)) and (absorbing absorb absorbed ) ) (((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))) AND (RESIST PHOTORESIST) ) ((LIN-SHUN LIN-SHUN-LI HSU-W HSU-WEI HSU-WEI-H HSU-WEI-HSUAN HSU-WEI-HUA) and ((polarized adj light ) ((s p)-polarized)) and ((electric electrical magnetic magnet) near field)) ((LIN-SHUN LIN-SHUN-LI HSU-W HSU-WEI HSU-WEI-H HSU-WEI-HSUAN HSU-WEI-HUA) and (resist photoresist)) ))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 21:11
-	10	((((electromagnetic magnetic electric ) adj field ) and ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE ) and (resist photoresist)) not (((((oxygen adj plasma) same (electromagnetic magnetic electric )) and (resist photoresist)) and (polarized adj light)) (((electromagnetic adj field) ((electric magnetic) adj field)) and (polarized adj light) and (anti-etching antietching (anti adj etching)) and (absorbing absorb absorbed ) ) (((((PMDA.u/c.) pyromellitic adj dianhydride ) AND ((ODA.U/C.) (DDE.U/C.) 4,4\$1-DIAMINODIPHENYLETHER DIAMINODIPHENYLETHER (DIAMINODIPHENYL ADJ ETHER) OXYDIANILINE 4,4\$1-OXYDIANILINE )) AND ((s-polarized p-polarized) (polarized adj light ))) AND (RESIST PHOTORESIST) ) ((LIN-SHUN LIN-SHUN-LI HSU-W HSU-WEI HSU-WEI-H HSU-WEI-HSUAN HSU-WEI-HUA) and ((polarized adj light ) ((s p)-polarized)) and ((electric electrical magnetic magnet) near field)) ((LIN-SHUN LIN-SHUN-LI HSU-W HSU-WEI HSU-WEI-H HSU-WEI-HSUAN HSU-WEI-HUA) and (resist photoresist)) ))) and (polarized adj light)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/15 21:11